INTRODUCTION TO X-RAY AND GAMMA-RAY DETECTORS FOR PHYSICS PRINCIPLES AND TECHNOLOGIES

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TUTORIAL OUTLINE

- **1.** Introduction to X-rays and gamma-rays
- 2. Light-matter interaction
 - Types of detectors and performance criteria
 - Semiconductor diodes

3.

4.

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5. Semiconductor detectors with integrated electronics

1. INTRODUCTION TO X-RAYS AND GAMMA RAYS





• Electromagnetic spectrum

- Corpusculary theory: Light as quanta of energy **E** = **h**. v = **h**.c / λ
- Unit: electron-volt E = q.V = 1,6.10⁻¹⁹ J = 1 eV



Blurred border between X-rays and gamma-rays around 100 keV

- X-rays: light from electronic transitions
- Gamma rays: light from nuclear transitions



CONTINUOUS EMISSION PROCESSES

- Thermal emission: Planck's law and Wien's law
- **Bremsstrahlung emission**: electron deceleration in Coulombian collision with other electrons, ions, nuclei.

• Synchrotron emission: electron acceleration in magnetic field







LIGHT-MATTER INTERACTION

Photoelectric effect Compton scattering Pair effect

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PHOTOELECTRIC EFFECT

- Total absorption of the photon and release of a photoelectron of kinetic energy $E_c = E_0 E_B$
- The energy E_c is transferred to other atoms which are ionized in turn \rightarrow creation of a free charge cloud.
- **ο** The atom de-excitates and releases the left energy E_B.







• All scattering directions are not equiprobable (Klein-Nishina formula)

• The recoil electron can have an energy between 0 and E_C (Compton front energy): $E_C = \frac{E_0}{1 + \frac{mc^2}{2E_0}}$



• Conversion of the photon energy in mass energy and kinetic energy:

- Creation of the **electron-position pair** if $E_0 > 2.mc^2$ (1.022 MeV)
- The electron and the positron step by step lose their energy in the medium.
- The positron will annihilate with a electron by emitting **2 photons of 511 keV** in opposite directions.
 - These photons will escape and interact by photoelectric effect or Compton scattering.





- Apparent surface area of a target particle to explain its probability of interaction with the photon.
- The cross sections depend on the atomic number Z of the material.





INTERACTION... AND WHAT NEXT?

- **Primary ionisation**: creation of a photoelectron by one of the 3 defined processes
 - Photoelectric, Compton, pair
- Secondary ionisations: the photoelectron transfers its energy to the medium.
 - Creation of a charge cloud
- De-excitation of the electronic cortege to a stable state
 - Radiative (fluorescence) or not transitions
- **De-excitation of the cristalline network** (for a solid-state detector) to a stable state
 - Back to thermodynamic equilibrium



3. Type of detectors and performance criteria







BOLOMETERS

 Definition: instrument showing a temperature excess caused by the absorption of incident particle (or photon flux) → requires a cooling < 1 K. They are called cryogenic microcalorimeters.

o Detection chain

- Conversion of the photon energy in temperature pulse by an absorber.
- Conversion by the thermistance in contact in detectable electrical pulse.
- Limitation of the counting rate because of slow de-excitation (ms).





GASEOUS DETECTORS

- Ionising chambers filled with gas (He, Ar, CH_4).
- Direct detection of ionising electrons and ions.
- Used in the proportional regime: proportional counters (spectroscopy)

o Detection chain

- Creation of electron-ion pairs by photoelectric effect
- Charge drift towards collection electrode (due to electrical field)
- Readout of the signal by front-end electronics
- Segmenting the anode and measuring the time of arrival allows determining the photoelectron trajectories (imaging, polarimetry)
- Gas Electron Multiplier (1997, Sauli): region of intense electric field to provoke an avalanche phenomenon and create a detectable current for the front-end electronics.





o Detection chain

- 1. Conversion of the incoming energy in visible or UV light
 - The atom excited by the photon absorption will desexcite by emitting fluorescence photons (10 ps) or phosphorescence photons (> 1 μs).
- 2. Conversion of the scintillations in electrical pulse by a photomultiplier, direct coupled or through waveguide.
- 3. Detection and energy measurement by front-end electronics



Anticoincidence detector for Simbol-X space mission



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SEMICONDUCTOR DETECTORS

• Energy band structure

- The voids left by electrons in the valence band can be considered as positive charges called holes.
- The electrical conduction in this media type is insured by the movement of electrons in the conduction band and the movement of holes in the valence band.





• Detection chain (similar to gaseous detectors)

- Creation of electron-holes pairs by photoelectric effect
- Drift of electrons towards anode and holes towards cathode
- Signal readout by front-end electronics.



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Total efficiency

QUANTUM EFFICIENCY

 η_{tot} =

Number of detected quanta

Number of incoming quanta

• For spectroscopy applications (energy measurement), the relevant parameter is the **peak efficiency**

 $\eta_{\rm P} = \frac{\text{Number de fully absorbed quanta}}{1}$

Number of incoming quanta

 The efficiency depends on the material choice (absorption coefficient μ) and the thickness choice (x).



@300 K	Gaseous	Scintillators	Semiconductors	
Detector	Ar	Csl	Si	CdTe
μ/ρ (cm²/g)	0,204	2,035	0,183	1,671
η @100 keV for e = 1 mm	0,15 %	60 %	4,2 %	62 %



SPECTRAL RESOLUTION

- Smallest measurable energy difference. Full width at half maximum of the spectral line.
- o Intrinsic spectral resolution (limit)

Gas and semiconductors

 The ionisation statistics follows a Poisson law with a so-called Fano factor.

$$\Delta E_{stat} = 2,35 \cdot \sqrt{F \cdot \varepsilon \cdot E_{\gamma}}$$

 ϵ : Pair creation energy

X-ray spectroscopy

- Energy Resolution at 5.9 keV (Mn-Kα)
 - Gas: 885 eV (15 %)
 - Si : **123 eV** (2%)
 - TES Bolometer : **3 eV** (0,05%)

Bolometers

$$\Delta E = 2,35 \cdot \xi \sqrt{k_B T^2 C_T}$$

Gamma-ray spectroscopy

- Energy resolution at 1.33 MeV (Co60-γ)
 - Ge: 2 keV (0.15 %)
 - Nal : > 5 %
 - BGO : 10 %



• Maximal number of detectable events per time unit.

- Depends on the whole detection chain:
 - Relaxing time of the detector
 - Collecting time of the signal (charge drift)
 - Filtering time of front-end electronics (to minimise noise)
 - Readout / acquisition / processing time (system sizing)
- Orders of magnitude
 - TES (transition edge sensor) bolometers: 10³ cps/s
 - Gaseous: 10⁴ cps/s
 - Semiconductor: 10⁵ cps/s
 - Scintillator + PM: 10⁷ cps/s

4. SEMICONDUCTOR DIODES



POSITION SENSITIVE SENSORS

• Segmented semiconductor detectors - working principle:

- The whole detector volume is sensitive to radiation.
- The signal is mainly induced in the electrode which is the closest to the photon interaction and the charge drift. Shockley-Ramo theorem for charge induction.
- Signal can be induced on several electrodes: charge sharing, split events.

• Pixel detectors

- The signal induction is favored by the small pixel effect.
- No ambiguity in the interaction position.

o Double-sided strip detectors

- Highest segmentation (10-100 μm)
- Connection to a large number of analog channels on the sides.





STATE-OF-THE-ART TECHNOLOGIES

• Segmentation processes: chimical, optical, mechanical (photolithography)

o Si

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- Thickness of 250 to 450 μm, surface up to 10 cm side (8 inch wafer)
- Pixelisation down to 15 μm, typ. 50 μm for X-ray applications

• Cd(Zn)Te

- Thickness of 0.5 to 2 mm with CdTe,
- 2 to 10 mm with CZT, surface up to 3 cm side
- Strips ~50 μm, pixels ~200 μm

o Ge

- 10 to 15 mm thickness (efficacité gamma)
- Conventional diodes (N-type Li, P-type B) : 2 mm pitch
- Blocking contacts with metallic film (LBNL):
 0.5 mm pitch



5. SEMICONDUCTORS DETECTORS WITH INTEGRATED ELECTRONICS

Silicon Drift Detectors (SDD) Coupled Charge Device (CCD) Active pixels sensors (APS)

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SILICON DRIFT DETECTORS (SDD)

X-ray spectroscopy



Drift towards the structure centre

Low anode capacitance for low electronic noise.

X-ray imaging



Drift towards a segmented anode

Use of the diffusion to determine the drift time and the position x_0



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Introduction to X-ray and gamma-ray detectors



COUPLED CHARGE DEVICE (CCD) : STRUCTURE

MOS CCD

 Structure derived from a classical MOS structure by dividing the metallic electrode into strips.



- Double pn diode structure
 → Full depletion over the total wafer thickness (up to 450 µm)
 - \rightarrow Quantum efficiency of 90 % at 10 keV

Pn-CCD



COUPLED CHARGE DEVICE (CCD) : READOUT

Readout principle (in 4 steps)

- 1. Detection of incoming photons by photoelectric effect.
- 2. Charge accumulation in the MOS capacitance (or underneath the pixel structures).
- 3. Charge transfer step by step towards the anode and the first stage of signal amplification (electronics placed on the substrate).
 - 1. For each pixel: one collecting electrode, two barrier electrodes
 - 2. Channel (P-)stops perpendicular to electrodes to avoid charge planar diffusion
- 4. Readout of the signal by external front-end electronics



ACTIVE PIXEL SENSORS: STRUCTURE

- The detector integrates the sensitive part and the first stage of signal amplification. The signal is measured locally (no transfer).
 - Example: Depleted p-channel field effect transistor (DePFET)
- Technological challenges:
 - Substrates and fabrication standards a priori non compatible
 - Double side fabrication processes

Charge sensitive amplifier (FET) with doped silicon

Sensitive area with fully depleted high resisitivity silicon (high charge carrier lifetime)



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ACTIVE PIXEL SENSORS: READOUT

- Transistors are switched on row by row to read a current proportionnal to the charge stored in the pixel.
- Columns are read in parallel thanks to an external front-end electronics.





Credits: MPG-HLL

EZ.

